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	Application No.	Applicant(s)	
	10/728,517	KIM ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Toniae M. Thomas	2822	
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communicatio IGHTS. This application is subject	pplication. If not include n will be mailed in due	ed course. THIS
1. \boxtimes This communication is responsive to <u>the amendment filed</u>	on 27 December 2006.		
2. The allowed claim(s) is/are <u>1-6,11-34 and 40</u> .			
 Acknowledgment is made of a claim for foreign priority ur a)	been received. been received in Application No	•	tion from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	ENT of this application.		•
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMINEF es reason(s) why the oath or declar	R'S AMENDMENT or Nation is deficient.	OTICE OF
5. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.		
(a) including changes required by the Notice of Draftspers	_	-948) attached	
1) hereto or 2) to Paper No./Mail Date			
(b) including changes required by the attached Examiner's Paper No./Mail Date	•		
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	.84(c)) should be written on the drawing the header according to 37 CFR 1.121	ings in the front (not the (d).	back) of
DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MATERIAL FOR THE DEPOSIT OF BIOLOGIC	must be submitted. N CAL MATERIAL.	Note the
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal F	Patent Application	
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	* *	
3. ☑ Information Disclosure Statements (PTO/SB/08),	Paper No./Mail Da 7.	te	
Paper No./Mail Date <u>03/14/07</u> 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ☑ Examiner's Statement of Reasons for Allowance 9. ☐ Other		
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Information Disclosure Statement

1. The information disclosure statement (IDS) submitted on 14 March 2007 has been considered. While the IDS has been considered note that the US patent citation, US 5,665,646, has been lined through, since the patent was previously cited by the examiner and relied upon in the Office action mailed on 27 September 2006 (see the Office action mailed on 27 September 2006 and the PTO-892 Form attached thereto).

Reasons for Allowance

- 2. The following is an examiner's statement of reasons for allowance: Applicant's arguments filed on 27 December 2006 with respect to the rejection of claims 11-13, 16, 18, and 19 under 35 USC §103(a) as being unpatentable over Kitano (US 5,665,646) in view of Stols (US 6,200,942 B1) are persuasive. Specifically, the argument that "one [having] ordinary skill in the art would not look to Stols to remove both the titanium film and TiN layer while not removing the TiSi₂ layer in manufacturing a CMOS semiconductor device" (see Remarks page 9, lines 5-7). Accordingly, the rejection is withdrawn.
- 3. The prior art of record fails to anticipate, teach or suggest, either separately or combined: a method of selectively removing metal layers using a cleaning solution, which comprises an acid solution, water, and an iodine-containing oxidation agent selected from the group consisting of NH4IO3, LilO3, CalO3, BalO3, KI, and NH4I, as recited in claim 1; a method of selectively removing a metal layer in a process for forming a silicide layer.

wherein the method comprises cleaning a non-reacting metal layer that does not participate in the silicidation reaction using a cleaning solution that includes an acid solution and an oxidation agent containing iodine, as recited in claim 11; or a method of selectively removing a metal layer in a process for forming a silicide layer, wherein the method comprises performing a cleaning that removes both a titanium nitride layer and a non-reacting metal layer using a cleaning solution comprising an acid solution, an iodine-containing oxidation agent, and water, as recited in claim 25.

4. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Friday from 8:30 a.m. to 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service

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Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

TMT 17 March 2007

M. Wilczewski Primary Examiner TC 2800

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